



Serial No. 09/867,830

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Volker Lehmann Examiner: Elizabeth S. Quan
Serial No.: 09/867830 Group Art Unit: 1743
Filed: May 30, 2001 Docket No.: 3035.12-US-W1
Title: ARRANGEMENT FOR TAKING UP LIQUID ANALYTES

CERTIFICATE UNDER 37 C.F.R. 1.8: The undersigned hereby certifies that this document is being deposited in the United States Postal Service, as first class mail, with sufficient postage, in an envelope addressed to: Mail Stop RCE, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on February 1, 2005.

Mary Johnston
Name

Mary Johnston
Signature

CONCISE STATEMENT OF RELEVANCE UNDER 37 CFR 1.98(A)(3)

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated August 2, 2004, Applicant provides herewith a concise statement of relevance, as follows:

1. DE238444 (intended to be the patent publication DD 238444 A1) describes a dosing device for carrying out chemical analyses and for dosing in microtitre and submicrotitre regions. The dosing device allows the sucking and/or emitting of pre-defined liquid or gas amounts from or into a plurality of wells by means of a multiple dose pipette arrangement. However, in our understanding, DE239444 A1 is silent about any analysis chip that is located in the flow path of the analyte from the well into the pipette and into the chamber or from the chamber into the pipette and into the respective well between the pipette and the chamber.

2. DE 19700626 A1 described a method for feeding probe materials from a probe providing place to a probe receiving place by means of a probe feeding member and provides the steps that the probe feeding member comprises at least one material portion made of porous material wherein the pores have such a size that the probe material is held in the porous material in liquid phase due to capillary forces during the probe provision by means of the probe processing device.
3. EP 0296348 A1 describes an etched method for manufacturing wire openings or trenches in n-doped silicon.

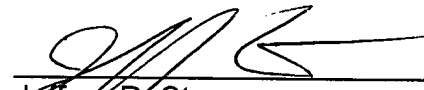
Respectfully submitted,

Altera Law Group, LLC
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Date:

2/1/05

By:



Jeffrey R. Stone
Reg. No. 47,976
JRS/MEJ

List of References

~~100 arrangement~~

~~101 microtitre plate~~

~~102 well~~

~~103 further plate~~

~~104 pump~~

~~105 detail~~

~~201 analyte~~

~~202 pipette~~

~~203 lower plastic body~~

~~204 upper plastic body~~

~~205 intermediate plate~~

~~206 analysis chip~~

~~207 diaphragm~~

~~208 walls~~

~~209 upper chamber~~

~~210 space~~

~~211 first diaphragm position~~

~~212 second diaphragm position~~

~~213 buffer plate~~

~~214 lower chamber~~

~~401 pipette~~

~~402 well~~

~~403 analyte~~

~~404 arrow~~

~~405 lower region pipette~~

~~406 diaphragm~~

~~407 pore~~

~~501 pore opening~~

~~502 air~~

~~503 meniscus~~